



IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant: Daniel Alvarez, Jr. and Jeffery J. Spiegelman

Application No.: 10/692,018 Group: 1724

Filed: October 23, 2003 Examiner: Frank M. Lawrence, Jr.

Confirmation No.: 8519

For: METHOD FOR PURIFICATION OF LENS GASES  
USED IN PHOTOLITHOGRAPHY

CERTIFICATE OF MAILING OR TRANSMISSION	
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AMENDMENT

Mail Stop Amendment  
Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

Sir:

This Amendment is being filed in response to the Office Action mailed from the U.S. Patent and Trademark Office on August 26, 2005, in the above-identified application. Reconsideration and further examination are requested.

A one-month extension of time to respond to the Office Action is respectfully requested. A Petition for a One-Month Extension of Time and the appropriate fee are being filed concurrently with this Amendment.

Please amend the application as follows:

12/30/2005 ZJU HAR1 00000027 10692018

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